

(Example)

T.U. Microsyllabus

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Q.1 The energy gap E_g in silicon is 1.1 eV. The average electron effective mass is $0.31 m_e$, where m is the free electron mass. Calculate the electron concentration in the conduction band of Si at room temp^r, $T = 300\text{K}$. Assume $E_p = \frac{E_g}{2}$.

Ans:

We have,

$$N_e = 2 \left(\frac{2\pi m_e^* k_B T}{h^2} \right)^{\frac{3}{2}} e^{\frac{E_p - E_g}{k_B T}}$$

$$\text{Here, } m_e^* = 0.31 m_e = 0.31 \times 9.1 \times 10^{-31} \text{ kg.}$$

$$k = 1.38 \times 10^{-23} \text{ J K}^{-1}$$

$$h = 6.62 \times 10^{-34} \text{ J s}^{-1}$$

$$\therefore N_e = 4.36 \times 10^{-3} e^{\left(\frac{0.55 \text{ eV} \times 1.6 \times 10^{-19}}{1.38 \times 10^{-23} \times 300} \right)}$$

$$\therefore E_p = E_g/2$$

$$= 2.6 \times 10^{15} / \text{m}^3 \quad \#$$

Q25.2 (worked example)

A sample of Si is doped with phosphorus. The donor impurity level lies 0.045 eV below the bottom of the conduction band. At $T = 300\text{ K}$, E_F is 0.010 eV above the donor level. Calculate

- the impurity concentration,
- the no. of ionised impurities,
- the free electron concentration and
- the hole concentration.

(For Si, $E_g = 1.1\text{ eV}$, $m_e^* = 0.31m$, $m_h^* = 0.38m$)

Solution:

We have,

$$N_c e^{-(E_F - E_D)/k_B T} = N_v e^{-(E_F - E_g)/k_B T} + N_D \left[1 - e^{-(E_D - E_F)/k_B T} \right] \quad \text{--- (1)}$$

$$\begin{aligned} \text{Here, } N_c &= 2 \left(\frac{2\pi m_e^* k_B T}{h^2} \right)^{3/2} \\ &= 2 \left(\frac{2\pi \times 0.31 \times 9.1 \times 10^{-31} \times 1.38 \times 10^{-23} \times 300}{(6.62 \times 10^{-34})^2} \right)^{3/2} \\ &= 4.39 \times 10^{24} \text{ m}^{-3} \end{aligned}$$

$$\begin{aligned} N_v &= 2 \left(\frac{2\pi m_h^* k_B T}{h^2} \right)^{3/2} \\ &= 2 \left(\frac{2\pi \times 0.38 \times 9.1 \times 10^{-31} \times 1.38 \times 10^{-23} \times 300}{(6.62 \times 10^{-34})^2} \right)^{3/2} \\ &= 5.95 \times 10^{24} \text{ m}^{-3} \end{aligned}$$

Substituting these values along with E_p and E_D in eqⁿ (1) above, one gets

$$4.39 \times 10^{24} e^{\left[-\frac{(1.1 - 1.065)}{0.025} \right]} = 5.95 \times 10^{24}$$

$$e^{\left(-\frac{1.065}{0.025} \right)} + N_D \left[1 - \frac{1}{e^{\left(-\frac{0.010}{0.025} \right)} + 1} \right]$$

$$9, \quad 1.08 \times 10^{24} = 1.88 \times 10^6 + N_D (0.40)$$

$$\therefore N_D = 2.7 \times 10^{24} \text{ m}^{-3}$$

(b) For the ionized no. of impurities,

$$N_D^+ = N_D \left[1 - \frac{1}{e^{\frac{E_D - E_F}{k_B T}} + 1} \right]$$

$$= 2.7 \times 10^{24} \left[1 - \frac{1}{e^{\left(\frac{-0.010}{0.025} \right)} + 1} \right]$$

$$= 1.08 \times 10^{24} \text{ m}^{-3}$$

(c) The free electron concentration,

$$n_e = 2 \left(\frac{2\pi m_e^* k_B T}{h^2} \right)^{3/2} e^{\frac{E_F - E_g}{k_B T}}$$

$$= 4.39 \times 10^{24} e^{\frac{1.065 - 1.1}{0.025}}$$

$$= 1.08 \times 10^{24}$$

$$\begin{aligned}
 (d) \quad n_h &= 2 \left(\frac{2\pi m_h^* k_B T}{h^2} \right)^{3/2} e^{-E_F/k_B T} \\
 &= 5.95 \times 10^{29} e^{-1.065/0.025} \\
 &= 1.88 \times 10^6 \text{ m}^{-3}
 \end{aligned}$$

Problem 25.1.

The band gap in pure Ge is 0.67 eV.

(a) Calculate the no. of electrons per unit volume in the conduction band at 250 K, 300 K, and at 350 K.

(b) Do the same for Si assuming $E_g = 1.1 \text{ eV}$. The effective mass of the electrons in germanium is $0.12m$ and in Silicon $0.31m$, where m is the free electron mass.

Sol: Here,

Fermi energy for Ge, $E_F = E_p = \frac{E_g}{2} = \frac{0.67}{2} = 0.33 \text{ eV}$.

For $T_1 = 250 \text{ K}$,

$$\begin{aligned}
 n_e &= 2 \left(\frac{2\pi m_e^* k_B T}{h^2} \right)^{3/2} e^{-\frac{E_F - E_g}{k_B T}} \\
 &= 2 \left(\frac{2\pi \times 0.12 \times 9.1 \times 10^{-31} \times 1.38 \times 10^{-23} \times 250}{(6.62 \times 10^{-34})^2} \right)^{3/2} e^{-\frac{0.33 - 0.67}{1.38 \times 10^{-23} \times 250}} \\
 &= 1.528 \times 10^{17} \text{ m}^{-3}
 \end{aligned}$$

For $T_2 = 300\text{K}$,

$$n_e = 2 \left\{ \frac{2\pi \times 0.12 \times 9.1 \times 10^{-31} \times 1.38 \times 10^{-23} \times 300}{(6.62 \times 10^{-34})^2} \right\}^{3/2} e^{\frac{0.33 - 0.67}{1.38 \times 10^{-23} \times 300}}$$

$$= 2.63 \times 10^{18} \text{ m}^{-3}$$

and $T_3 = 350\text{K}$

$$n_e = 2 \left\{ \frac{2\pi \times 0.12 \times 9.1 \times 10^{-31} \times 1.38 \times 10^{-23} \times 350}{(6.62 \times 10^{-34})^2} \right\}^{3/2} e^{\frac{0.33 - 0.67}{1.38 \times 10^{-23} \times 350}}$$

$$= 2.09 \times 10^{20} \text{ m}^{-3}$$

For Silicon,
(Do yourself)

Problem 25.2

Suppose that the effective mass of hole in a material is four times that of electrons. At what temp^r would the Fermi level shifted by 10% from the middle of the forbidden energy gap? $E_g = 1\text{ eV}$.

Solⁿ:

Here, $m_h^* = 4m_e^*$

Let E_g be the forbidden energy gap and E_F the Fermi energy

The new Fermi energy,

$$E'_F = E_F + \frac{E_g}{2} \times 10\%$$

$$= \frac{E_g}{2} + \frac{E_g}{20} = \frac{11 E_g}{20}$$

Now, $E'_F = \frac{E_g}{2} + \frac{3}{4} kT \ln \left(\frac{m_h^*}{m_e^*} \right)$

$$\therefore \frac{11 E_g}{20} = \frac{E_g}{2} + \frac{3}{4} kT \ln 4.$$

$$\Rightarrow T = 567.70 \text{ K}.$$

Problem 4.3

The energy gap in Ge is 0.67 eV. The electron and the hole effective masses are 0.12 m and 0.23 m respectively, m is the free electron mass.

Calculate the (a) Fermi energy, (b) the electron density and (c) the hole density at $T = 300 \text{ K}$.

Solⁿ:

Here,

$$E_g = 0.67 \text{ eV} = 0.67 \times 1.6 \times 10^{-19} \text{ J}.$$

$$m_e^* = 0.12 m = 0.12 \times 9.1 \times 10^{-31} \text{ kg}.$$

$$m_h^* = 0.23 m = 0.23 \times 9.1 \times 10^{-31} \text{ kg}.$$

Fermi energy (E_F) = ?

Electron density (N_e) = ?

Hole density (N_h) = ?

$T = 300 \text{ K}.$

We have,

$$\begin{aligned}
 \textcircled{a} \quad E_p &= \frac{E_g}{2} + \frac{3}{4} kT \ln \left(\frac{m_n^*}{m_e^*} \right) \\
 &= \frac{0.67 \times 1.6 \times 10^{-19}}{2} + \frac{3 \times 1.38 \times 10^{-23} \times 300}{4} \ln \left(\frac{0.23 \text{ m}}{0.12 \text{ m}} \right) \\
 &= 5.36 \times 10^{-20} + 2.02 \times 10^{-21} \\
 &= 5.58 \times 10^{-20} \text{ J} \\
 &= \frac{5.58 \times 10^{-20}}{1.6 \times 10^{-19}} \text{ eV} = 0.348 \text{ eV}.
 \end{aligned}$$

$$\begin{aligned}
 \text{Now, } \textcircled{b} \quad N_e &= 2 \left(\frac{2\pi m_e^* k_B T}{h^2} \right)^{3/2} e^{-\frac{E_p - E_g}{k_B T}} \\
 &= 2 \left(\frac{2\pi \times 0.12 \times 9.1 \times 10^{-31} \times 1.38 \times 10^{-23} \times 300}{h^2} \right)^{3/2} e^{-\frac{5.58 \times 10^{-20} - 0.67 \times 1.6 \times 10^{-19}}{1.38 \times 10^{-23} \times 300}} \\
 &= 3.26 \times 10^{18} \text{ m}^{-3}.
 \end{aligned}$$

$$\begin{aligned}
 \text{and } \textcircled{c} \quad N_h &= 2 \left(\frac{2\pi m_h^* k_B T}{h^2} \right)^{3/2} e^{-\frac{E_p}{k_B T}} \\
 &= 2 \left(\frac{2\pi \times 0.23 \times 9.1 \times 10^{-31} \times 1.38 \times 10^{-23} \times 300}{(6.62 \times 10^{-34})^2} \right)^{3/2} e^{-\frac{5.58 \times 10^{-20}}{1.38 \times 10^{-23} \times 300}} \\
 &= 1.05 \times 10^{19} \text{ m}^{-3}.
 \end{aligned}$$

Problem 25.13

A certain intrinsic semiconductor has a band gap E_g is 0.2 eV. Measurement shows that it has a resistivity at room temp of 0.3 Ωm . What would you predict its resistivity to be at 350 K?
(T.U 2074)

Solⁿ:

Here,

$$E_g = 0.2 \text{ eV} = 0.2 \times 1.6 \times 10^{-19} \text{ J}$$

$$\rho \text{ at } 300\text{K} = 0.3 \Omega\text{m} \Rightarrow \rho_1 = ?$$

$$\rho \text{ at } 350\text{K} = ? \Rightarrow \rho_2 = ?$$

For intrinsic semiconductor, $n_e = n_h = 2 \left(\frac{2\pi k_B T}{h^2} \right)^{3/4} e^{-E_g/2k_B T}$
From $\sigma = ne\mu$,

$$\sigma = |e| n_e (\mu_e + \mu_h)$$

$$\therefore \rho = \frac{1}{\sigma} = \frac{1}{|e| n_e (\mu_e + \mu_h)}$$

$$\Rightarrow \frac{\rho_1}{\rho_2} = \frac{|e| (n_e)_2 (\mu_e + \mu_h)}{|e| (n_e)_1 (\mu_e + \mu_h)}$$

$$= \frac{2 \left(\frac{2\pi k_B T_2}{h^2} \right)^{3/4} e^{-E_g/2k_B T_2}}{2 \left(\frac{2\pi k_B T_1}{h^2} \right)^{3/4} e^{-E_g/2k_B T_1}} = \left(\frac{T_2}{T_1} \right)^{3/4} e^{-\frac{E_g}{2k_B} \left(\frac{1}{T_2} - \frac{1}{T_1} \right)}$$

$$r, \frac{0.3}{s_2} = \left(\frac{350}{300} \right)^{3/2} e^{-\frac{0.2 \times 1.6 \times 10^{-19} (350 - 300)}{2 \times 1.38 \times 10^{-23} \times 350 + 310}}$$

$$= 2.19$$

$$\therefore s_2 = 0.136 \text{ nm.}$$

Problem 25.16

The energy gap in Si is 1.1 eV, whereas in diamond it is 6 eV. What conclusion can you draw about the transparency of the two materials to visible light (4000 \AA to 7000 \AA)

Ans:

Here,

$$E_g = 1.1 \text{ eV} = 1.1 \times 1.6 \times 10^{-19} \text{ J. (Si)}$$

$$E_g = 6 \text{ eV} = 6 \times 1.6 \times 10^{-19} \text{ J (diamond)}$$

We have, $E_g = h\nu = h \frac{c}{\lambda}$

$$\therefore \lambda = \frac{hc}{E_g}$$

For Si, $\lambda_c = \frac{6.62 \times 10^{-34} \times 3 \times 10^8}{1.1 \times 1.6 \times 10^{-19}}$

$$= 1.128 \times 10^{-6} \text{ m} > (4 \times 10^{-7} \text{ m})$$

Opaque.

For diamond,

$$\lambda_c = \frac{6.62 \times 10^{-34} \times 3 \times 10^8}{6 \times 1.6 \times 10^{-19}}$$

$$= 2.068 \times 10^{-7} \text{ m} < 4 \times 10^{-7} \text{ m.} \Rightarrow \text{Transparent.}$$